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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/851,231	05/07/2001	Peter Krulevitch	IL-10581	3998
7590 01/14/2004			EXAMINER	
Alan H. Thompson Assistant Laboratory Counsel Lawrence Livermore National Laboratory P.O. Box 808, L-703			SIMONE, CATHERINE A	
			ART UNIT	PAPER NUMBER
			1772	
Livermore, CA	94551		DATE MAILED: 01/14/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	—— ·	Application No.	Applicant(s)				
Office Action Summary		09/851,231	KRULEVITCH ET AL.				
		Examiner	Art Unit				
		Catherine Simone	1772				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SH THE I - Exter after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, eply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tim within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	ely filed will be considered timely. the mailing date of this communication. (35 U.S.C. § 133).				
1)🛛	Responsive to communication(s) filed on <u>08 O</u>	<u>ctober 2003</u> .					
2a) <u></u> ☐	This action is FINAL . 2b)⊠ This	action is non-final.					
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠	Claim(s) <u>1-16</u> is/are pending in the application.						
	4a) Of the above claim(s) <u>1-10</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
· · · · · · · · · · · · · · · · · · ·) Claim(s) <u>11-16</u> is/are rejected.						
	Claim(s) is/are objected to.						
8)[_	Claim(s) are subject to restriction and/or	r election requirement.					
Applicati	on Papers						
9) The specification is objected to by the Examiner.							
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. §§ 119 and 120							
12)							
Attachment(s) 1) Notice of References Cited (RTO 802)							
2) Notic	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal Pa	PTO-413) Paper No(s) atent Application (PTO-152)				

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on October 8, 2003 has been entered.

Withdrawn Rejections

2. The 35 U.S.C. 102 rejection of claims 11-16 as being anticipated by Lum et al. of record in Paper #4, Pages 2-3, Paragraph #2 has been withdrawn due to the Applicant's amendment in Paper #6.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 4. Claims 11-16 are rejected under 35 U.S.C. 102(e) as being anticipated by Chow (6,167,910).

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Chow discloses an apparatus having a sealed microchannel therein, comprising an etched substrate (Figs. 1A and 3A, #104), an etched microchannel (Fig. 1A, #124) in the etched substrate, an annealed substrate (Figs. 1A and 3A, #106) positioned on the etched substrate that covers the etched microchannel in the etched substrate, an annealed microchannel in the annealed substrate covering the etched microchannel in the etched substrate, and a bond connecting the etched substrate and the annealed substrate (see col. 5, lines 2-10 and 39-50), wherein the etched microchannel and the annealed microchannel comprise the sealed microchannel (Fig. 3A, #302). Regarding claim 12, note the annealed microchannel is a high temperature annealed microchannel annealed in the 600° to 800° range (see col. 5, lines 13-23). Regarding claim 13, note the etched microchannel in the substrate and the annealed microchannel in the annealed substrate form a circular sealed microchannel (Fig. 3B, #310). Regarding claim 14, note the etched substrate and the annealed substrate are selected from the group consisting of glass members, glass and silicon members, glass and polymer members and members selected from the group of glass, silicon and polymers (see col. 5, lines 3-5). Regarding claim 15, note the bond comprises fusion (see col. 5, lines 5-10 and 21-24). Regarding claim 16, note the annealed microchannel has a depth of about 10 µm and a width of about 20 µm (see col. 3, lines 45-57) and the annealed microchannel is a high temperature annealed microchannel annealed in the 600° to 800° range (see col. 5, lines 14-19).

Response to Arguments

5. Applicant's arguments with respect to claims 11-16 have been considered but are moot in view of the new ground(s) of rejection.

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Conclusion

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Catherine Simone whose telephone number is (571)272-1501. The examiner can normally be reached on 9:30-6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Harold Pyon can be reached on (571) 272-1498. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (571)272-0987.

Catherine Simone Examiner Art Unit 1772 December 29, 2003

SUPERVISORY PATENT EXAMINER